

IN THE SPECIFICATION:

Please insert the following at page 1, between lines 1 and 2:

--CROSS-REFERENCE TO RELATED APPLICATIONS

This application is a National Phase Application (35 USC 371) of PCT/JP2003/014780 and claims priority of Japanese Application No. 2002-336738 filed November 20, 2002 and of Japanese Application No. 2002-336739 filed November 20, 2002.--

Please substitute the following paragraph for that at page 6, lines 7-18:

--Optical characteristics of the fingerprint easily erasable film of the present invention may differ depending on the use, and they are not particularly limited. However, it preferably has high transparency as the whole film. Specifically, it preferably shows 82% or more of total light transmittance defined in JIS-K 7105:1981. Further, the film preferably shows a haze of 35.0% or less, more preferably 10% or less, further preferably 5.0% or less. The lower limit of the haze is preferably 1.5% or more. By making the haze fall within the range of 1.5 to 35.0%, ingredients of fingerprint remaining after wiping can be made invisible while maintaining transparency.--

Please substitute the following paragraph for that at page 7, lines 13-20:

--When the fingerprint easily erasable film of the present invention consists of a substrate alone as shown in Fig. 3, i.e., when the matted surface is formed as the surface of the substrate, a material showing high wet tension is preferred as the material constituting the substrate. Examples of the substrate showing high wet tension include polyester films, acrylic resin films and so forth.--